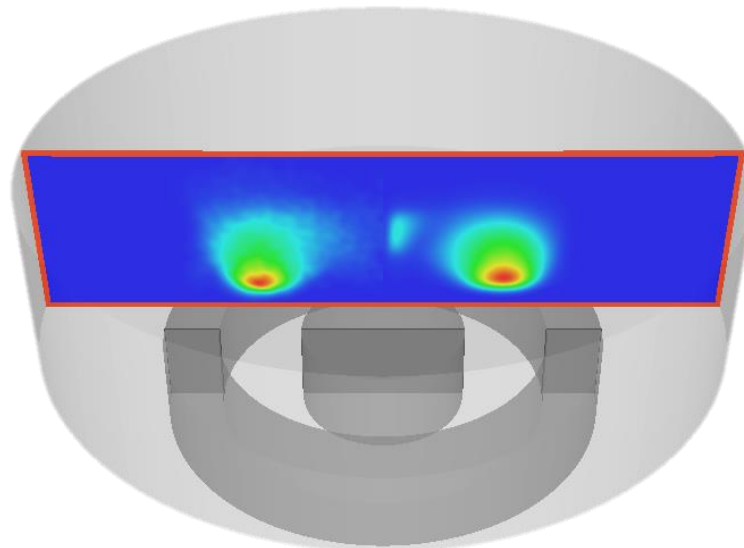


— CASE EXAMPLE —

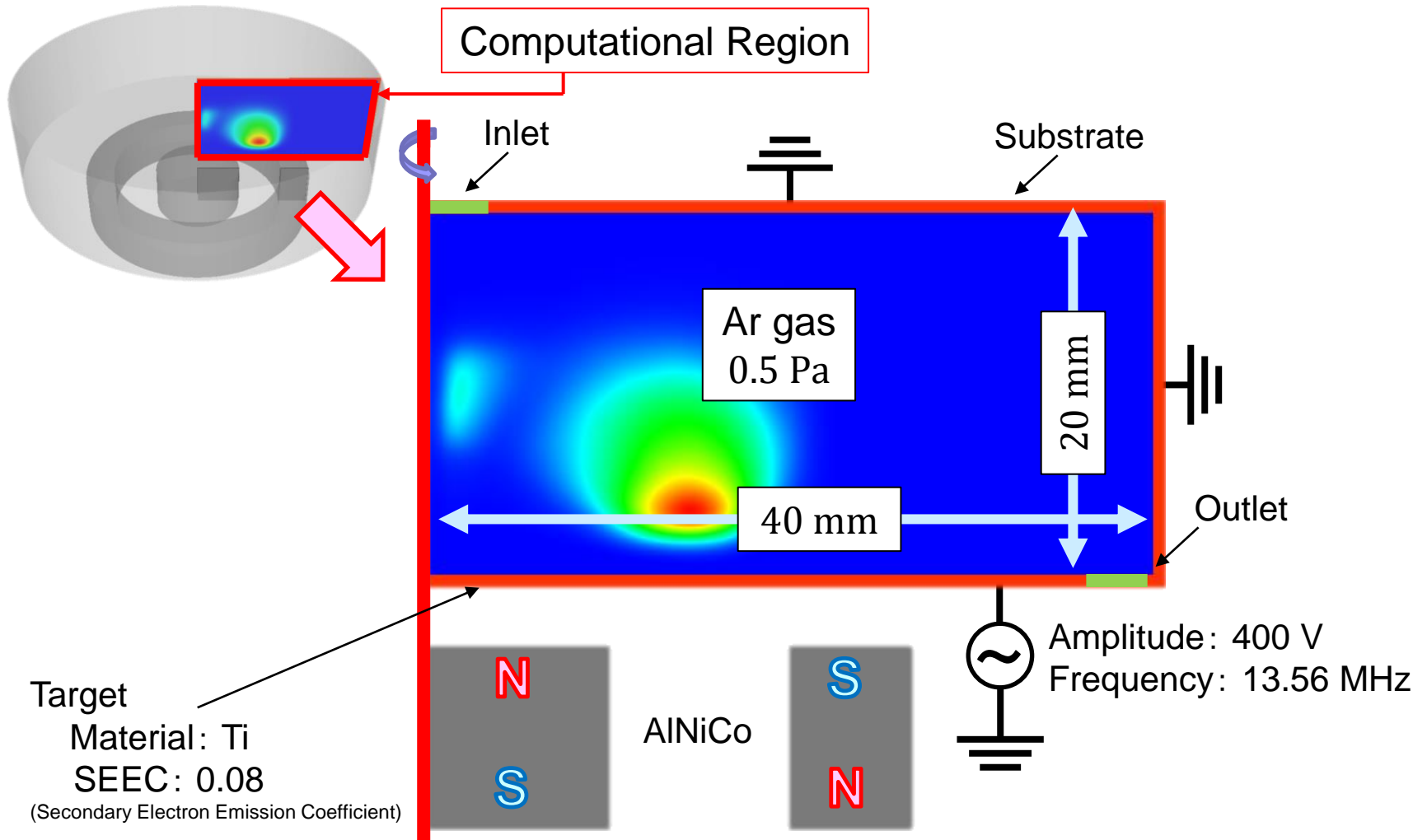
RF Magnetron Sputtering



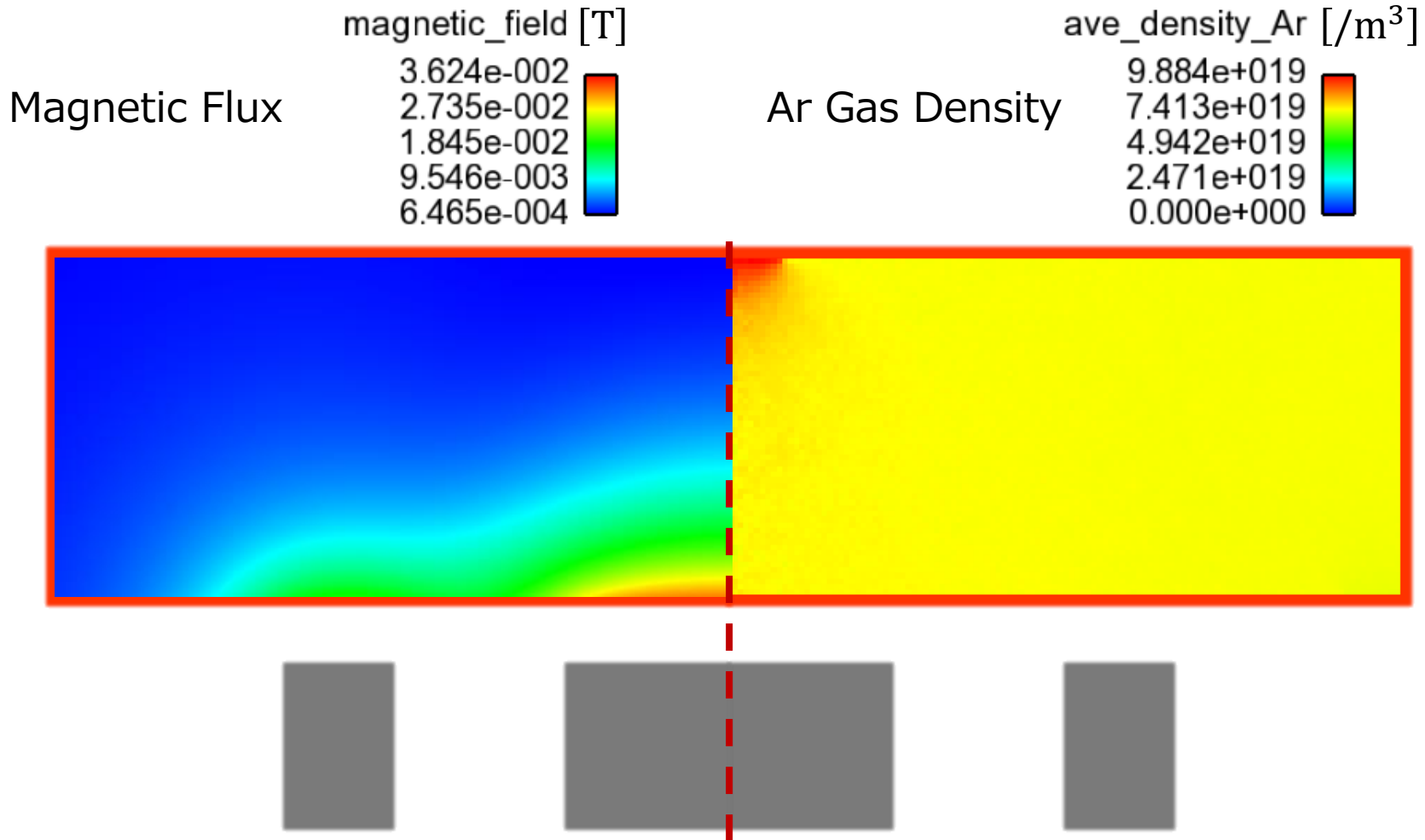
L: Ionization / R: Electron Density

Ti Deposition by Ar Plasma

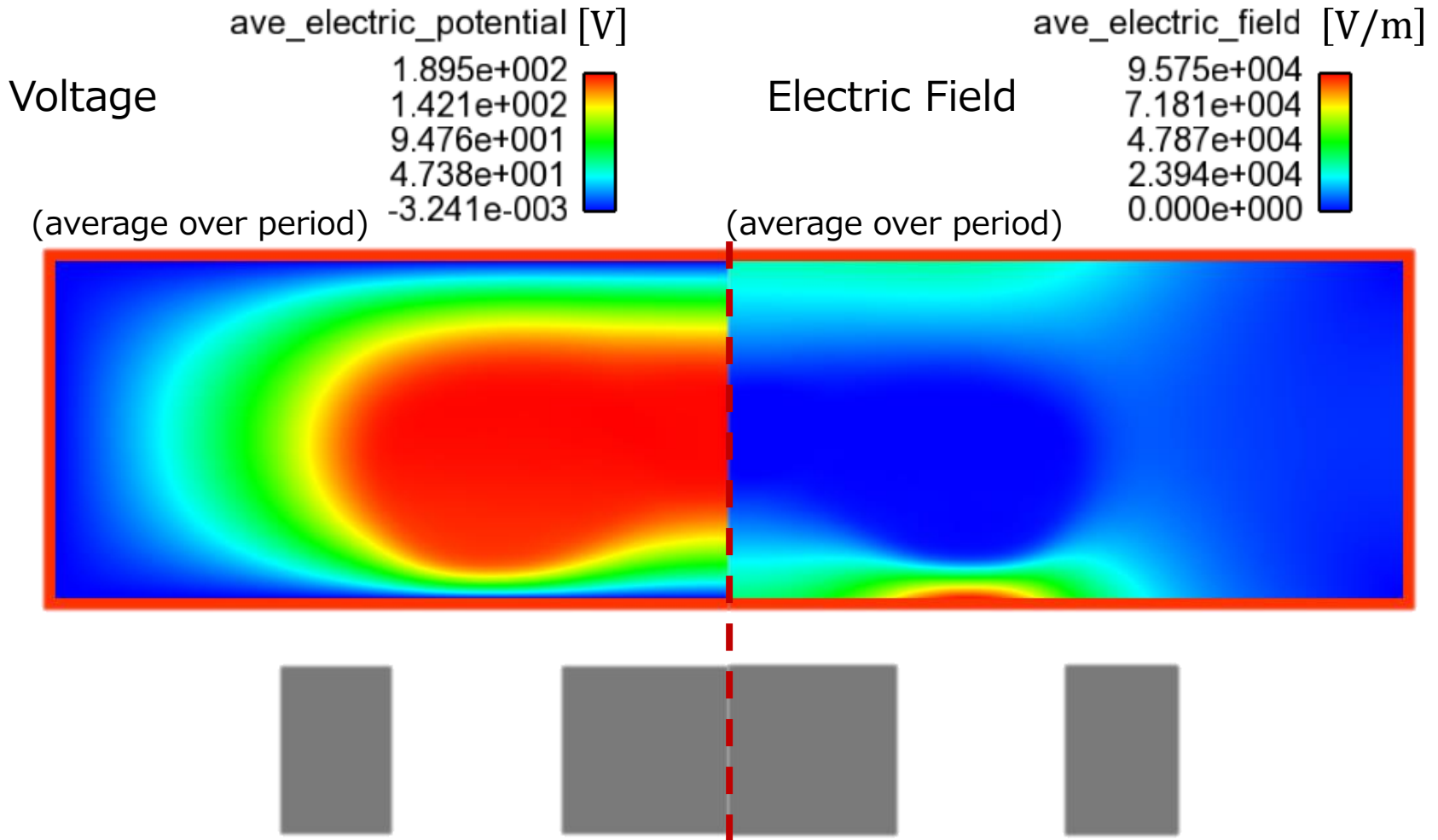
Axi-symmetric model



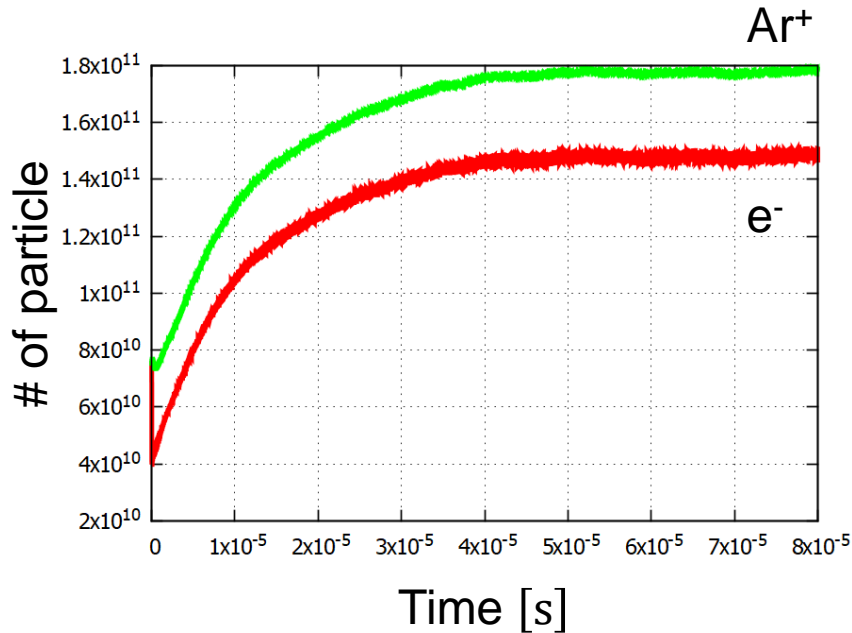
Magnetic Field and Gas Density



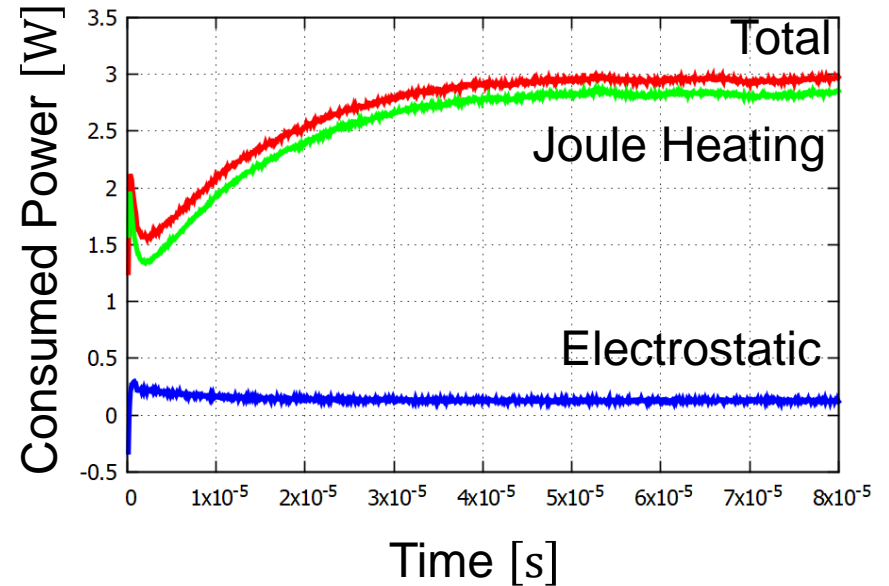
Voltage and Electric Field

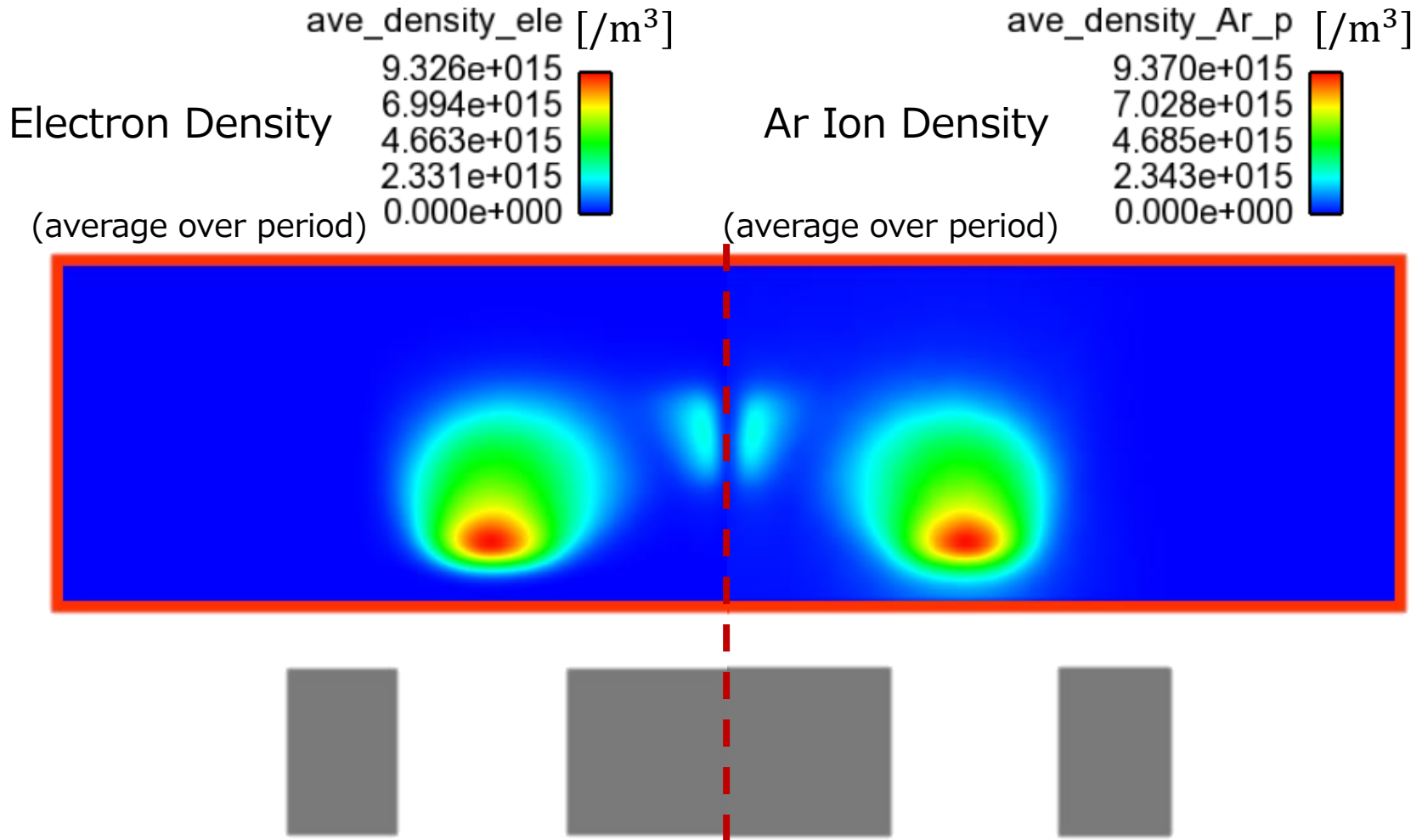


Number of Particle

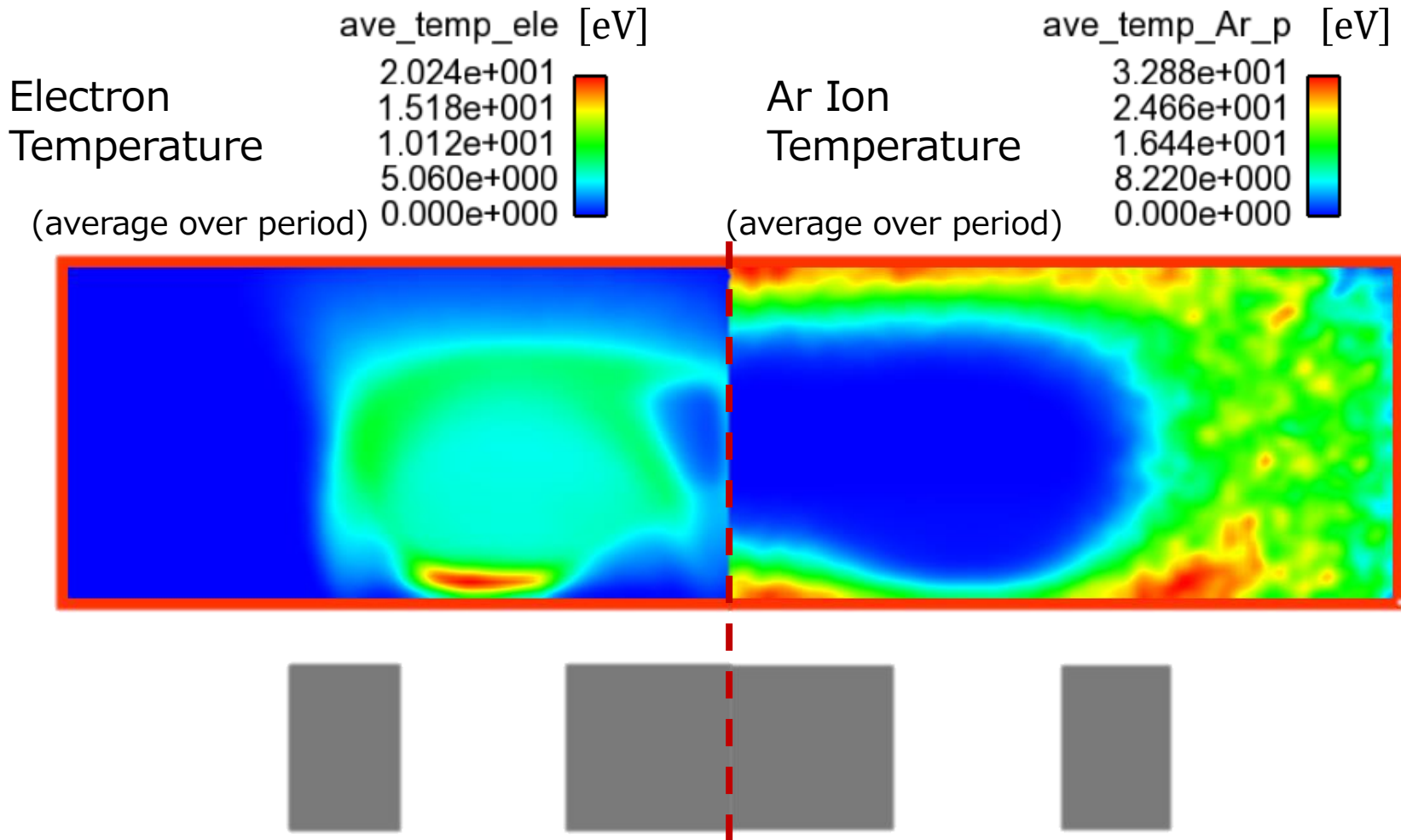


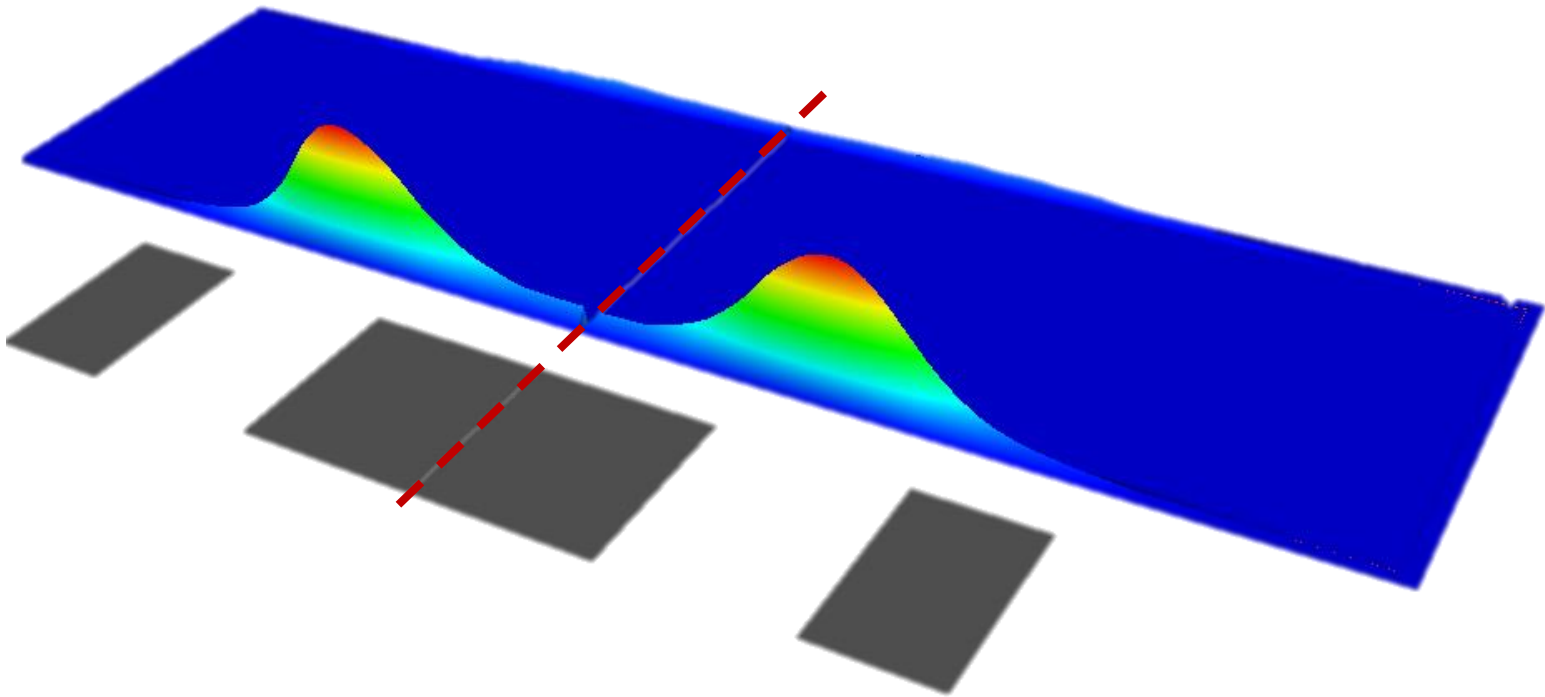
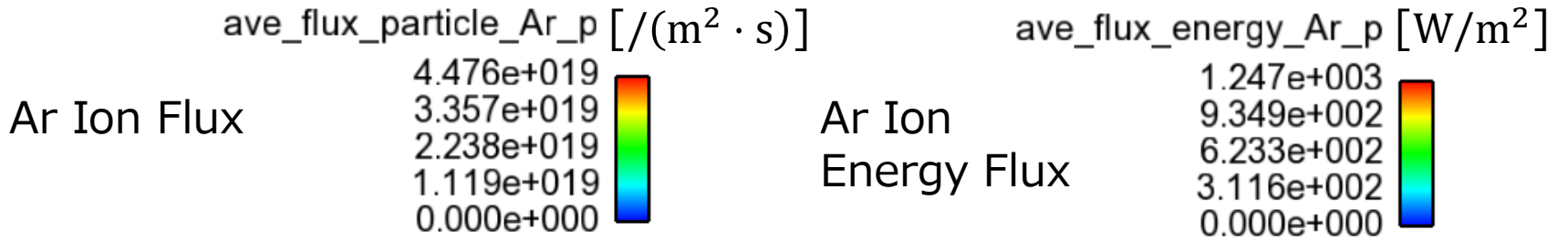
Consumed Power





Plasma Temperature





Sputtering and Deposition

